Notice of Allowability	Application No.	Applicant(s)	Applicant(s) OGATA ET AL	
	09/922,723	OGATA ET AL		
	Examiner	Art Unit		
	Sin J. Lee	1752		
The MAILING DATE of this communication appe All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIG	OR REMAINS) CLOSED or other appropriate comm GHTS. This application is	in this application. If not included nunication will be mailed in due cours		
1. This communication is responsive to <u>04-08-2004</u> .				
2. The allowed claim(s) is/are 1,3-5 and 8-17.				
3. \square The drawings filed on $___$ are accepted by the Examiner	•			
 4. Acknowledgment is made of a claim for foreign priority un a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	been received. been received in Applicati	on No	om the	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the requiren	nents	
5. A SUBSTITUTE OATH OR DECLARATION must be submi INFORMAL PATENT APPLICATION (PTO-152) which give			E OF	
 CORRECTED DRAWINGS (as "replacement sheets") must (a) including changes required by the Notice of Draftsperson 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the paper of the paper No./Mail DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F. 	on's Patent Drawing Revie Amendment / Comment on 84(c)) should be written on the header according to 37 C sit of BIOLOGICAL MAT	or in the Office action of the drawings in the front (not the back) FR 1.121(d). ERIAL must be submitted. Note the		
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/06 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ⊠ Interview S Paper No 8), 7. ⊠ Examiner's	nformal Patent Application (PTO-152 Summary (PTO-413), ./Mail Date <u>04152004</u> . s Amendment/Comment s Statement of Reasons for Allowance		

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EXAMINER'S AMENDMENT

- 1. Applicants canceled claims 6 and 7.
- 2. An extension of time under 37 CFR 1.136(a) is required in order to make an examiner's amendment which places this application in condition for allowance. During a telephone conversation conducted on April 15, 2004, Mr. Bruce E. Kramer (attorney for applicants) requested an extension of time for one MONTH(S) and authorized the Director to charge Deposit Account No. 19-4880 the required fee of \$110.00 for this extension and authorized the following examiner's amendment. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.
- 3. The application has been amended as follows:

In Claims 11-17, first line, change "positive resist composition" to --- base material ---.

4. The following is an examiner's statement of reasons for allowance: As previously indicated, Tokutake (JP'324) (either alone or in combination with Honda'304) does not teach or fairly suggest present siloxane unit (a2) or claim 1 which is a phenylsilsesquioxane unit. Also, as previously indicated, Tokutake (JP'324) applies his resist composition solution in uniform thickness of 1.3 micrometer (which converts to

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1300 nm) onto a silicon wafer, and the reference does not teach or fairly suggest the

present thickness range (50-200 nm) of claim 10 for the resist layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on

Statement of Reasons for Allowance."

5. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Sin J. Lee whose telephone number is 571-272-1333.

The examiner can normally be reached on Monday-Friday from 9:00 am EST to 5:30

pm EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark F. Huff, can be reached on 571-272-1385. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

S.J.L.

S. Lee April 15, 2004 Sin J. Lee

Patent Examiner

Technology Center 1700

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MARK F. HUFF SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700